

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Koji HASEGAWA et al.

Serial No.: 09/963,465

Filed: September 27, 2001

For: POLYMER, RESIST COMPOSITIONS AND PATTERNING PROCESS

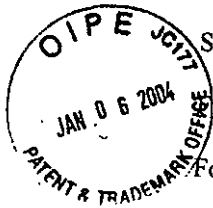
Group Art Unit: 1752

Examiner: Y. C. Thornton

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REPLY

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Office Action of October 20, 2003, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 13 of this paper.

OK  
to  
enter  
1-22-04  
JCW